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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Ryoji HOSHI et al.

Group Art Unit: 1765

Application No.: 10/525,244

Docket No.: 122810

Filed: February 22, 2005

For: SINGLE CRYSTAL, SINGLE CRYSTAL WAFER, EPITAXIAL WAFER, AND
METHOD OF GROWING SINGLE CRYSTAL

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

William P. Berridge
Registration No. 30,024

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Registration No. 51,156

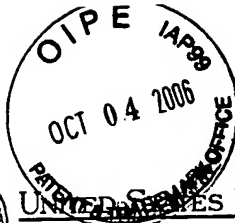
WPB:JML/mrs

Date: October 4, 2006

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/525,244	02/22/2005	1765	900	122810	5	20	2

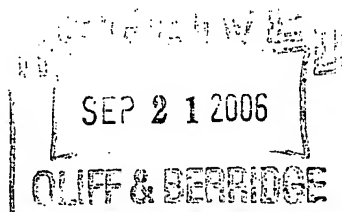
CONFIRMATION NO. 5373

CORRECTED FILING RECEIPT



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Applicant(s)

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Assignment For Published Patent Application

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 (CO., LTD.)

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/11443 09/08/2003

Foreign Applications

JAPAN 2002-267563 09/13/2002

If Required, Foreign Filing License Granted: 08/28/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/525,244**

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

Single crystal, single crystal wafer, epitaxial wafer, and method of growing single crystal

Preliminary Class

117

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